

L Number	Hits	Search Text	DB	Time stamp
-	17365	crystalli\$6 with catalyst	USPAT; US-PGPUB; EPO; JPO	2003/09/08 13:09
-	2090	((crystalli\$6 with catalyst) with amorphous	USPAT; US-PGPUB; EPO; JPO	2003/09/08 13:12
-	374	((crystalli\$6 with catalyst) with amorphous) and (crystalli\$6 with catalyst) with (heat\$3 anneal\$3)	USPAT; US-PGPUB; EPO; JPO	2003/09/08 13:13
-	374	((crystalli\$6 with catalyst) with amorphous) and (crystalli\$6 with catalyst) with (heat\$3 anneal\$3)) and (crystalli\$6 catalyst heat\$3 anneal\$3 cryatal)	USPAT; US-PGPUB; EPO; JPO	2003/09/08 13:12
-	124	((crystalli\$6 with catalyst) with amorphous) and (crystalli\$6 with catalyst) with (heat\$3 anneal\$3)) and (crystalli\$6 catalyst heat\$3 anneal\$3 cryatal)) and ((hydrogen 'H2') with amorphous)	USPAT; US-PGPUB; EPO; JPO	2003/09/08 13:14
-	380	((crystalli\$6 with catalyst) with amorphous) and (crystalli\$6 with catalyst) with (heat\$3 anneal\$3 irradiat\$4)	USPAT; US-PGPUB; EPO; JPO	2003/09/08 13:14
-	128	((crystalli\$6 with catalyst) with amorphous) and (crystalli\$6 with catalyst) with (heat\$3 anneal\$3 irradiat\$4)) and ((hydrogen 'H2') with amorphous)	USPAT; US-PGPUB; EPO; JPO	2003/09/08 13:15
-	83	((crystalli\$6 with catalyst) with amorphous) and (crystalli\$6 with catalyst) with (heat\$3 anneal\$3 irradiat\$4)) and ((hydrogen 'H2') with amorphous)) and ((substrate wafer) with (insulat\$ dielectric))	USPAT; US-PGPUB; EPO; JPO	2003/09/08 13:16
-	83	((crystalli\$6 with catalyst) with amorphous) and (crystalli\$6 with catalyst) with (heat\$3 anneal\$3 irradiat\$4)) and ((hydrogen 'H2') with amorphous)) and ((substrate wafer) with (insulat\$ dielectric))) and silicon	USPAT; US-PGPUB; EPO; JPO	2003/09/08 13:26